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SHEET 1 OF 1

INFORMATION DISCLOSURE CITATION IN AN APPLICATION						SERIAL NO. <b>10/620,432</b>				
(PTO-1449)				APPLICANT Hiroyuki FURUYA, et al.						
				FILING DATE GROUP <b>July 17, 2003</b> GROUP <b>2812</b>						
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EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes -Number 4 -Kind Codes (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Whe	Columns, Lines ere Relevant ures Appear	Translation			
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		JP 2002-110569 A (w/ English Abstract)	04/12/2002	MATSUSHITA ELECTRIC IND. CO., LTD.						
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1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.

SHEET 1 OF 1

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			APPLICANT Hiroyuki FURUYA, et al.							
(PTO-1449)				FILING DATE July 17, 2003	July 17, 2003 2812					
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